

In vitro prevention of the emergence of fosfomicin resistance in methicillin-resistant *Staphylococcus aureus* (MRSA)

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Background

Fosfomicin (FOS) has been shown to be effective against MRSA. However, its main drawback is the rapid emergence of *in vitro* resistance

Objective

Aim of the study was to evaluate if the selection of FOS-resistant MRSA strain could be prevented *in vitro* by combining FOS with rifampin (RIF), daptomycin (DAP), levofloxacin (LEV) and vancomycin (VAN).

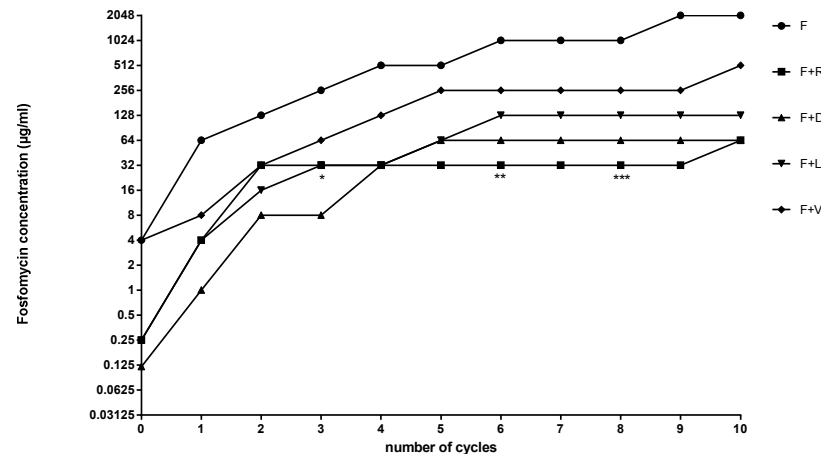
Methods

A reference MRSA strain (ATCC 43300) was used. The frequency of spontaneous resistance to FOS was tested by incubating for 24h 10⁹ CFU/ml of MRSA inoculated on FOS-containing agar plates. For progressive emergence of resistance, bacteria (10⁵ CFU/ml) were exposed to two-fold increasing concentrations of FOS alone and with 0.5xMIC of RIF, DAP, LEV and VAN for a total of 10 consecutive days. The stability of resistance to FOS was performed by subculturing FOS-resistant strain on antibiotic-free agar for 5 days. Susceptibility to RIF was determined at day 3,6,9 and 10 by gradient strip diffusion test.

Results

	FOS	RIF	LVX	DAP	VAN
MIC (BD)	4 µg/ml	0.008 µg/ml	0,25 µg/ml	0.5 µg/ml	1 µg/ml

Antimicrobial susceptibility test of MRSA ATCC 43300 performed by macrobroth dilution



*: E-test for Rifampin: 0.006mcg/ml
 **: E-test for Rifampin: 0.19 mcg/ml
 ***: E-test for Rifampin: 0.47-0.64 mcg/ml

Selection of FOS-resistant MRSA after serial exposure to FOS alone or in combination with 0.5xMIC of RIF, LVX, DAP and VAN.

- FOS resistance emerged rapidly and could not be prevented by the addition of LEV and VAN.
- The addition of RIF and DAP delayed the increase in the MIC of FOS.
- The MIC of RIF at day 10 was 0.19 µg/ml.

Conclusions

- FOS resistance rapidly developed *in vitro*.
- Addition of RIF and DAP only delayed the emergence of FOS resistance.
- FOS prevented the emergence of RIF resistance up to 10 days of progressive exposure to sub-inhibitory RIF concentrations.